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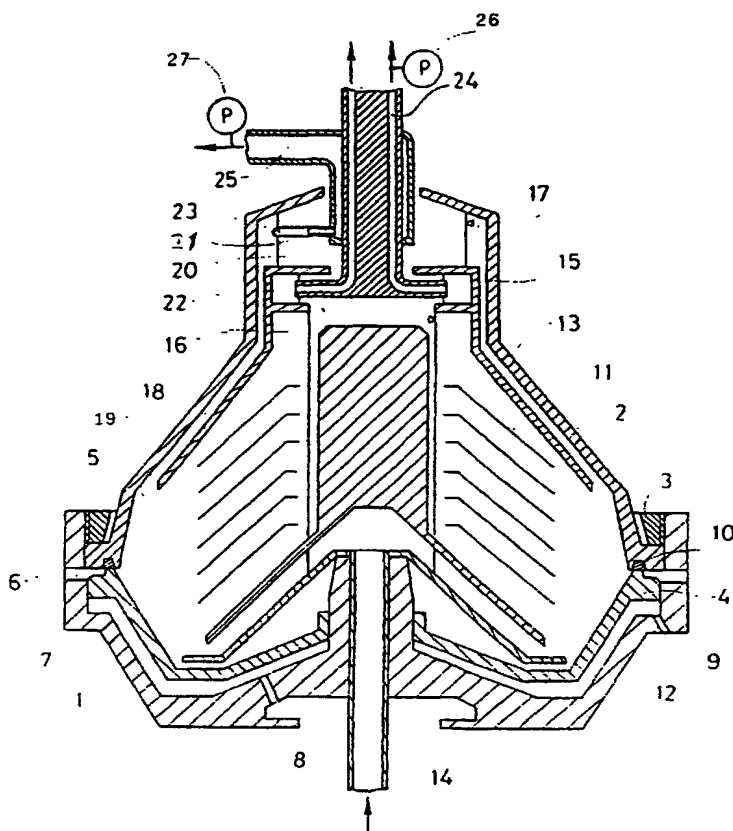
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(54) Title: A METHOD FOR ADJUSTING A RADIAL LEVEL OF AN INTERFACE IN A CENTRIFUGAL SEPARATOR



(57) Abstract: A method for adjusting an interface between a specific light liquid phase and a specific heavier liquid phase to a wanted radial level in a centrifugal separator, in which the separation chamber (5) is emptied and the inlet opening (23, 29) of a discharge device (21, 29) in an outlet chamber (17) for the heavy liquid phase is brought to a radial inner position. Then a pre-determined volume of the specific heavier phase is supplied to the separation chamber (5) and the mixture is supplied to the separation chamber (5), the interface formed between the two liquid phases being displaced radial outwardly and the displaced specific heavier liquid phase being pressed radial inwardly in the outlet channel (18) and into the outlet chamber (17). A first indicating means (26) indicates when the separation chamber (5) has been filled up and the inlet opening (23, 29) is moved towards the free liquid surface in the outlet chamber (17) until specific heavier liquid phase is discharged through the inlet opening (23, 29) and the discharge channel, which is indicated by means of the second indicating means (27). The inlet opening (23, 29) is prevented from moving at least radially outwardly from its obtained position corresponding to a wanted position of the interface. During the following normal operation the radial level position of the interface is maintained.

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